Lecture 6: Solid state synthesis

- The products are typically **single crystals**, **polycrystalline powders** or **thin films**
	- Recipes? Journal papers!
- Solid state reaction
- Low-temperature methods
- High-pressure synthesis
- Thin films
	- Chemical vapor deposition
	- Atomic layer deposition

Figure:<http://lulelaboratory.blogspot.fi/> Figure: Aalto University

Solid state reaction

See [Solid State Chemistry Wiki](https://wiki.aalto.fi/display/SSC/Solid+state+reaction)

- The oldest, simplest and still most widely used method to make inorganic solids
	- Mix together powdered reactants (and possibly press them into pellets)
	- Heat in a furnace for prolonged periods
- **Diffusion in solids is very slow**, thus high temperatures are needed
	- Although the reactants may be well mixed at the level of individual particles (e.g. μm scale), they are very inhomogeneous on the atomic level
- Solid state reactions are under **thermodynamical control**
	- The most stable phase or mixture at the reaction conditions will form
	- Reaction mechanisms and kinetics are usually not known well
	- Separating impurity phases from the product is usually impossible

Example: MgAl₂O₄ spinel

- Let's consider a solid state reaction of MgO and Al_2O_3 powders to MgAl₂O₄ spinel
- Close-packed anions in all three compounds

$MgAl₂O₄$ spinel from MgO and $Al₂O₃$

Ref: West p. 190

- The first few atomic layers of product nuclei may form easily, but subsequent growth or thickening of the product is more difficult
	- $-$ The two reactants, MgO and Al₂O₃, are separated by a spinel layer.
- A complex counter-diffusion process of Mg²⁺ and Al^{3+} ions is required
- As the reaction proceeds, the spinel layer thickens, the diffusion path length increases, and the reaction slows down (Mg^{2+} and Al^{3+} diffuse very slowly)
- Heating for **1 week at 1500°C** would be required to form a fairly pure spinel product

Idealized reaction mixture composed of grains of MgO and Al₂O₃. In practice, the grains will be irregular and not so arranged. Spinel formation occurs at the interfaces

Some practical considerations for solid state reactions

- The MgAl₂O₄ spinel synthesis is difficult since both reagents, MgO and Al₂O₃, are very stable, inert, non-reactive solids
	- Solid state reactions may be easier if one or more of the starting materials is chemically reactive and/or contains ions that can diffuse easily
- Other possible problems:
	- Loss of reactants by evaporation (e.g. alkali metal oxides, PbO, Bi₂O₃, HgO)
	- Reactivity towards the container (e.g. transition metal -containing materials).
- Issues to consider when planning a solid state reaction:
	- Choice of starting materials (purity, reactivity, how finely they are ground)
	- Container (Pt / Ta / Au / Al₂O₃ / SiO₂ / graphite)
	- Heat treatment conditions (temperature program)
	- Atmosphere, especially oxygen partial pressure (pO₂) for oxides
		- Oxidizing (Air, O_2)
		- Inert or slightly reducing (vacuum, N_2 , Ar)
		- Strongly reducing $(H_2/Ar$ mix, $H_2)$

Solid state reaction of Li_4SiO_4

• Lithium orthosilicate Li_4SiO_4 is the parent phase for a family of Li⁺ ion conductors that can be prepared by the following reaction (24 h at **~800 °C**):

 $2Li_2CO_3 + SiO_2 \rightarrow Li_4SiO_4 + 2CO_2$

- Problems:
	- $-$ Li₂CO₃ melts and decomposes above ~720 °C.
	- It also is reactive towards most container materials, including Pt and silica glass.
- Solution:
	- Use gold containers
	- Carry out decomposition and pre-reaction of Li₂CO₃ at ~650 °C for a few hours before final firing at 800–900 $^{\circ}$ C overnight.

SiO⁴ (*P* 1 21/*m* 1)

Use of homogeneous, singlesource precursors

- Prepare a crystalline, homogeneous, single-phase precursor material that contains all the required cations in the correct ratio.
- Precursor should decompose to the desired product on heating.
- As an example, let's see how $NH_4Fe(CrO_4)_2$ can be used as a precursor to FeCr_2O_4 .
- The precursor is synthetized by precipitation from aqueous solution:

Fe³⁺ (aq) + 2CrO₄²⁻ (aq) + NH₄⁺ (aq) \rightarrow NH₄Fe(CrO₄)₂

The precursor decomposes on heating (at $1150 °C$): NH_4 Fe(CrO₄)₂ \rightarrow 2FeCr₂O₄ + 2NH₃ + H₂O + 7/2 O₂

FeCr2O⁴ (*Fd*-3*m*) *ccp* anions (spinel, like $MgAl₂O₄$)

Low temperature methods

- Low temperature methods can be used to achieve atomic scale mixing of reactants, in gas, liquid, or even solid phases
	- Final heating at high *T* may be needed, especially for ceramic products
- May enable higher purity products than high temperature solid-state reaction, especially if prolonged heating at high temperature can be avoided
	- No contamination from container materials and furnace atmosphere
- Products with high chemical homogeneity are usually obtained
- Disadvantages:
	- Reagents are often costly and difficult to handle on a large scale
	- Considerable research may be required to optimize the synthesis of a particular material
	- Once suitable conditions have been found, they may not be readily applicable to the synthesis of related materials

Sol–gel method

See [Solid State Chemistry Wiki](https://wiki.aalto.fi/display/SSC/Sol-gel+synthesis)

- The first stage is to prepare a homogeneous solution containing all the cationic ingredients in the desired ratio
- The solution is gradually dried and should transform
	- First to a viscous **sol** (particles of colloidal dimensions, ~1-1000 nm)
	- Finally to a transparent, homogeneous, amorphous solid known as a **gel**
	- Without precipitation of any crystalline phases
- The gel is then heated at high temperatures to remove volatile components trapped in the pores of the gel or chemically bonded hydroxyl and organic sidegroups and to crystallize the final product.

Alkoxide sol–gel method

- Organometallic precursors, particularly alkoxides, are widely used for the small-scale synthesis of known or new materials
	- Alkoxide: [R-O⁻]M⁺ (for example, [CH₃-O⁻]Na⁺)
- The alkoxide-based sol–gel method is extremely versatile and can incorporate most elements of the periodic table

4.3.1.1 Synthesis of $MgAl_2O_4$

Appropriate reagents are $Mg(OCH_3)_2$ and $Al(O^sBu)_3$. On mixing, hydrolysis, condensation and drying, an amorphous gel is obtained that decomposes to form very fine particles of spinel after final heating at 250° C. This compares very favourably, in energy terms, with solid state reaction, which typically requires heating for several days at $1500 \degree C$, but the alkoxide reagents are expensive, hygroscopic and difficult to use.

4.3.1.2 Synthesis of silica glass

Pure silica glass is difficult, and expensive, to prepare by traditional melting since molten $SiO₂$ is extremely viscous, even at 2000 °C (the melting point of SiO₂ is ~1700 °C). Starting from TEOS, it is possible by the sol-gel route to prepare an amorphous product which, to all intents and purposes, resembles silica glass but has never been heated above 1200 °C. Both silica glass and this amorphous silica look-alike are metastable and care is required to avoid some crystallisation at the final processing temperature of 1200° C.

TEOS = Tetraethyl orthosilicate

High-pressure chemistry

High-pressure chemistry (1)

See [Solid State Chemistry Wiki](https://wiki.aalto.fi/display/SSC/High-pressure+synthesis)

- High pressures (> 1 GPa = 10 000 atm) enable the synthesis of huge number of new materials that are unattainable in the atmospheric pressure
- In ultra-high pressures (Mbar range, > 100 GPa), the compression energy rivals or even exceeds the energy of the chemical bond!
	- New materials that are completely unintuitive from the "normal" point of view

High-pressure chemistry (2)

Paul F. McMillan, *Chem. Soc. Rev.*, **2006**, *35*, 855 ([DOI](http://doi.org/10.1039/B610410J))

- By the time a typical solid or liquid is compressed to above a few hundred thousand atmospheres, its molar volume is reduced by approximately 50%
- Once the megabar range (*p* > 100 GPa) is reached, average interatomic distances can be decreased by up to a factor of two.
- Major changes will occur in the outer electron shells, leading to substantial modifications of the chemical and physical properties.
- Even the arrangement of the periodic table has to be reconsidered for high pressure conditions.
- As a simple example, let's consider the typical alkaline earth metals such as Ca and Sr that possess a fully close-packed *fcc* structure at ambient conditions.
- Pressurising Ca to *p* > 200 kbar (20 GPa) causes it to transform to a *less efficiently* packed *bcc* structure with a lower coordination of the metal atoms
	- Pressure-induced mixing occurs between 3d and 4s electronic shells, giving Ca the character of a *d*-metal rather than an alkaline earth element

High-pressure chemistry (3)

- Ultimately, most substances should become metallic at the most extreme pressures, as the close approach of atoms results in electronic overlap
- In moderate pressures (*p* < 10 GPa), the pressure effects are not as extreme as in ultra-high pressures and typical phenomena are for example the increase of coordination number and the change of the structure type
	- In moderate pressures, a huge number of new materials that are only metastable in atmospheric pressure can be realized
	- Often the new materials remain intact in atmospheric pressure (e.g. diamond!)

Solid	Structure and coordination number	Typical transformation conditions		High-pressure structure
		P/kbar	$T \cap C$	and coordination number
C	Graphite, 3	130	3000	Diamond, 4
CdS	Wurtzite, 4:4	30	20	Rock salt, 6:6
KC1	Rock salt, 6:6	20	20	CsCl, 8:8
SiO ₂	Quartz, 4:2	120	1200	Rutile, 6:3
Li ₂ MoO ₄	Phenacite, 4:4:3	10	400	Spinel, 6:4:4
NaAlO ₂	Ordered	40	400	Ordered
	Wurtzite, 4:4:4			Rock salt, 6:6:6

High-pressure polymorphism of some simple solids Table 4.5

Multi-anvil press

- Sample is compressed between anvils, either cubic or octahedral
- Heating by running a current through graphite
- Pressures of up to 20 GPa (200 000 atm)
- Used mainly for materials synthesis
- Characterization done mainly *ex-situ* (outside the press)

Octahedral 8-anvil with eight corner-cut cubes enclosing an octahedral sample space (Kawai cell) [https://wiki.aalto.fi/display/SSC/High](https://wiki.aalto.fi/display/SSC/High-pressure+synthesis)[pressure+synthesis](https://wiki.aalto.fi/display/SSC/High-pressure+synthesis)

Figures: Linda Sederholm / Aalto

Diamond anvil cell

Figure: Choong-Shik Yoo, Washington State University

The most incompressible metal osmium at static pressures above 750 gigapascals <https://doi.org/10.1038/nature14681>

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Great demonstrations from Dr. Timothy Strobel: <https://www.youtube.com/watch?v=pxrQxgC01zE&t=19s>

Transparent dense sodium

NATURE | Vol 458 | 12 March 2009 Yanming Ma^{1,2}, Mikhail Eremets³, Artem R. Oganov^{2,4}†, Yu Xie¹, Ivan Trojan³, Sergey Medvedev³, Andriy O. Lyakhov²; Mario Valle⁵ & Vitali Prakapenka⁶

156 GPa

199 GPa

Na-Na distance decreases from **3.72 Å** to **1.89 Å**

Na 3s valence electrons are pushed to the interstitial space

Na metal transforms to optically transparent "self-salt" (Na⁺ / interstitial e[−])

Structure of Na-*hP*4 (*P*6³ */mmc*) predicted by USPEX

Thin-film techniques

Figure: [MPA industrie](https://www.mpa.fr/cvd-reactors.php)

Chemical Vapor Deposition reactor for TiC, TiCN, Al_2O_3 , and TiN deposition on hard metals and steels

Chemical Vapor Deposition (1)

See [Solid State Chemistry Wiki](https://wiki.aalto.fi/pages/viewpage.action?pageId=132189691)

- Important technique of making high-purity thin films and coatings for
	- Industrial applications, especially in electronics,
	- Fundamental scientific research
- Precursor molecules containing the elements of interest are **decomposed in the gas phase** and the products deposit as thin films.

Chemical Vapor Deposition (2)

- Example of a simple, volatile precursor molecule:
	- $-$ SiH₄ \rightarrow Si (polycrystalline) + 2 H₂
- Other examples of CVD processes
- To deposit compounds such as GaAs, a mixture of precursors is needed
- An alternative for GaAs is to use (organometallic) **single-source precursors** which contain all the elements of interest and in the correct ratio
- Examples of **metal-organic CVD** (MOCVD):

 $SiCH_2CH_3$ ₄ + 14O₂ \longrightarrow $SiO_2 + 8CO_2 + 10H_2O$ GeH₄ \xrightarrow{hv} Ge + 2H₂ $CrCl_2 + H_2 \xrightarrow{600\degree C} Cr + 2HCl$ $W(CO)₆ \rightarrow W + 6CO$ $Fe(C_5H_5)$, + 7/20, \rightarrow Fe + 10CO + 5H₂O Ga(CH₃)₃ + AsH₃ $\xrightarrow{\text{heat}}$ GaAs + 3CH₄

Atomic Layer Deposition (1)

- See Solid [State Chemistry](https://wiki.aalto.fi/pages/viewpage.action?pageId=168067176) Wiki
- Database of ALD review papers: <https://www.atomiclimits.com/reviewbase-aldale/>
- Database of ALD processes: <https://doi.org/10.6100/alddatabase>

Atomic Layer Deposition (2)

FIGURE 1

Schematic of ALD process. (a) Substrate surface has natural functionalization or is treated to functionalize the surface. (b) Precursor A is pulsed and reacts with surface. (c) Excess precursor and reaction by-products are purged with inert carrier gas. (d) Precursor B is pulsed and reacts with surface. (e) Excess precursor and reaction by-products are purged with inert carrier gas. (f) Steps 2-5 are repeated until the desired material thickness is achieved.

Atomic Layer Deposition (3)

- ALD is based on sequential, self-limiting reactions
	- Offers exceptional conformality on high aspect ratio structures
	- Thickness control at the Ångstrom level (usually \sim 10-100 nm thickness; max \sim 1 μ m)
	- Tunable film composition
- Powerful tool for many industrial applications (for example, microelectronics)

Figure 3. Cross-sectional SEM image of an Al_2O_3 ALD film with a thickness of 300 nm on a Si wafer with a trench structure.

Additional solid-state synthesis methods in SSC Wiki

- <https://wiki.aalto.fi/display/SSC/Solid-state+synthesis+methods>
- [Hydrothermal and solvothermal synthesis](https://wiki.aalto.fi/display/SSC/Hydrothermal+and+solvothermal+synthesis)
- [Spin coating](https://wiki.aalto.fi/display/SSC/Spin+coating)
- [Microwave synthesis](https://wiki.aalto.fi/display/SSC/Microwave+synthesis)
- [Chemical vapor transport \(CVT\)](https://wiki.aalto.fi/pages/viewpage.action?pageId=203116762)
- [Electrochemical deposition](https://wiki.aalto.fi/display/SSC/Electrochemical+deposition)
- [Spark plasma sintering for synthesis](https://wiki.aalto.fi/display/SSC/Spark+plasma+sintering+for+synthesis)
- [Ball milling as a synthesis method](https://wiki.aalto.fi/display/SSC/Ball+milling+as+a+synthesis+method)
- <https://wiki.aalto.fi/display/SSC/Sputtering>
- [Plasma-Enhanced Atomic Layer Deposition \(PEALD\)](https://wiki.aalto.fi/display/SSC/Plasma-Enhanced+Atomic+Layer+Deposition)
- [Molecular layer deposition \(MLD\)](https://wiki.aalto.fi/pages/viewpage.action?pageId=165129786)
- [Atomic Layer Etching \(ALE\)](https://wiki.aalto.fi/pages/viewpage.action?pageId=206572606)
- [Solid state synthesis from the perspective of green chemistry](https://wiki.aalto.fi/display/SSC/Solid+state+synthesis+from+the+perspective+of+green+chemistry)